



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Jack O. Chu et al.

: Date: April 1, 2003

Serial No.: 09/989,770

: Group Art Unit: 2815

Confirmation No.: 2335

: Examiner: Jesse A. Fenty

Filed: November 20, 2001

: Attorney Docket No.: YOR919980460US2

For: High Speed Composite p-Channel Si/SiGe Heterostructure for Field Effect Devices

Commissioner for Patents
Initial Patent Examination Division
Washington, D.C. 20231

RECEIVED
APR 11 2003
TECHNOLOGY CENTER 2800

#8
Election

4/10/03

Response to Restriction Requirement

Sir:

In response to the Requirement for Restriction dated December 18, 2002, Applicants elect Group II, Claims 43-72, drawn to a method of making semiconductor devices, classified in class 438, subclass 1+.

Group I, Claim 42, drawn to a semiconductor device, classified in class 257, subclass 19 is withdrawn from further prosecution and non-elected.

Further favorable action and allowance of the claims is earnestly requested.

Respectfully submitted,
Attorney for the Applicant(s)

By:

Robert M. Trepp

Registration No. 25,933

IBM Corporation
Intellectual Property Law Department
P. O. Box 218
Yorktown Heights, N.Y. 10598
Telephone No.: (914) 945-3147
Fax No.: (914) 945-3281